



Attorney Docket: 061063-0311751
Client Reference: OSP-16220

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of:
SHIBAYAMA, ET AL.

Confirmation Number: 8933

Application No.: **10/506,534**

Group Art Unit: 1722

Filed: September 3, 2004

Examiner: HITESHEW, Felisa Carla

Title: PROCESS FOR PRODUCING SILICON SINGLE CRYSTAL LAYER AND SILICON
SINGLE CRYSTAL LAYER

AMENDMENT UNDER 37 C.F.R. § 1.111

Mail Stop Non-Fee Amendments

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the Office Action dated May 18, 2006, the period for reply being extended by three (3) months to November 20, 2006 (November 18 = Saturday) by the corresponding petition and fee, please amend the above-identified application as follows: